

L Number	Hits	Search Text	DB	Time stamp
1	336	ALD and plasma and silicide	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 13:27
2	0	20020197881.URPN.	USPAT	2004/10/22 11:46
3	0	20020146895.URPN.	USPAT	2004/10/22 11:50
4	0	6709989.URPN.	USPAT	2004/10/22 12:03
12	403	plasma and (atomic adj layer adj deposition) and silicide	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 13:40
13	97	(plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide)	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:00
21	511	438/682.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:01
22	8	438/682.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:01
23	3	(438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:01
24	653	438/683.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:02
25	13	438/683.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:02
26	4	(438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:02
27	644	438/685.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:48
28	47	438/685.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:48

29	33	(438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:49
30	99	("4796082" "5593562" "4568960" "5217943" "6576062" "6773970" "6703296" "5320880" "5652181" "5882399" "6420260" "4557943" "4617237" "4443930" "4568565" "5719410" "4978420" "5236868" "5403435" "5478780" "5928966" "6100193" "4411734" "5246887" "5344792" "5554488" "5686761" "5693562" "5736455" "5801095" "5849092" "5904561" "5926743" "5933760" "5990493" "5994211" "6026762" "6117345" "6146988" "6204550" "4453305" "4464701" "4570328" "4605947" "4777061" "4777150" "4786360" "4795722" "4839304" "4894693").pn.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:42

31	312	438/686.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:50
32	22	438/686.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:51
33	14	(438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:51
34	9	((438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:51
35	577	438/597.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:51
36	8	438/597.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:51
37	4	(438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:51
38	1	((438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:52
39	194	438/630.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:52

40	4	438/630.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:52
41	2	(438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:52
42	1	((438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:52
43	728	438/648.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:58
44	21	438/648.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:58
45	13	(438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:59
46	4	((438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 14:59

47	455	438/649.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:00
48	4	438/649.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:00
49	1	(438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01
50	1	((438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01
51	155	438/650.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01
52	11	438/650.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01
53	1	(438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01

54	0	((438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:02
55	114	438/651.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01
56	1	438/651.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01
57	0	(438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:01
58	903	438/655.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:02
59	3	438/655.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:02

60	0	(438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:02
61	895	438/656.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:03
62	17	438/656.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:03
63	3	(438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:03

64	1	((438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:03
65	127	438/676.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:04
66	5	438/676.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:04
67	2	(438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:04

68	0	((438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition)))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition)))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma 438/677.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:03
69	257		USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:04
70	8	438/677.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:04
71	0	((438/677.ccls. and (ald or (atomic adj layer adj deposition))) and (438/676.ccls. and (ald or (atomic adj layer adj deposition)))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide)))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:05
72	746	438/758.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:05
73	28	438/758.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:05

79	2	438/762.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:06
80	0	(438/762.ccls. and (ald or (atomic adj layer adj deposition))) not (438/761.ccls. and (ald or (atomic adj layer adj deposition))) and (438/758.ccls. and (ald or (atomic adj layer adj deposition))) not (438/677.ccls. and (ald or (atomic adj layer adj deposition))) and (438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:06
81	954	438/763.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:06
82	20	438/763.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:06

83	0	(438/763.ccls. and (ald or (atomic adj layer adj deposition))) not (438/762.ccls. and (ald or (atomic adj layer adj deposition))) not (438/761.ccls. and (ald or (atomic adj layer adj deposition))) and (438/758.ccls. and (ald or (atomic adj layer adj deposition))) not (438/677.ccls. and (ald or (atomic adj layer adj deposition))) and (438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:07
84	148	438/765.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:07
85	8	438/765.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:07

86	0	(438/765.ccls. and (ald or (atomic adj layer adj deposition))) and (438/763.ccls. and (ald or (atomic adj layer adj deposition))) not (438/762.ccls. and (ald or (atomic adj layer adj deposition))) not (438/761.ccls. and (ald or (atomic adj layer adj deposition))) and (438/758.ccls. and (ald or (atomic adj layer adj deposition))) not (438/677.ccls. and (ald or (atomic adj layer adj deposition))) and (438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:07
87	230	438/769.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:07
88	9	438/769.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:07

89	0	(438/769.ccls. and (ald or (atomic adj layer adj deposition))) not (438/765.ccls. and (ald or (atomic adj layer adj deposition))) and (438/763.ccls. and (ald or (atomic adj layer adj deposition))) not (438/762.ccls. and (ald or (atomic adj layer adj deposition))) not (438/761.ccls. and (ald or (atomic adj layer adj deposition))) and (438/758.ccls. and (ald or (atomic adj layer adj deposition))) not (438/677.ccls. and (ald or (atomic adj layer adj deposition))) and (438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:07
90	967	438/778.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:08
91	51	438/778.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:08

92	0	(438/778.ccls. and (ald or (atomic adj layer adj deposition))) not (438/769.ccls. and (ald or (atomic adj layer adj deposition))) not (438/765.ccls. and (ald or (atomic adj layer adj deposition))) and (438/763.ccls. and (ald or (atomic adj layer adj deposition))) not (438/762.ccls. and (ald or (atomic adj layer adj deposition))) not (438/761.ccls. and (ald or (atomic adj layer adj deposition))) and (438/758.ccls. and (ald or (atomic adj layer adj deposition))) not (438/677.ccls. and (ald or (atomic adj layer adj deposition))) and (438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide)) 438/785.ccls.	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:08
93	535		USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:08
94	102	438/785.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:08

95	0	(438/785.ccls. and (ald or (atomic adj layer adj deposition))) not (438/778.ccls. and (ald or (atomic adj layer adj deposition))) not (438/769.ccls. and (ald or (atomic adj layer adj deposition))) not (438/765.ccls. and (ald or (atomic adj layer adj deposition))) and (438/763.ccls. and (ald or (atomic adj layer adj deposition))) not (438/762.ccls. and (ald or (atomic adj layer adj deposition))) not (438/761.ccls. and (ald or (atomic adj layer adj deposition))) and (438/758.ccls. and (ald or (atomic adj layer adj deposition))) not (438/677.ccls. and (ald or (atomic adj layer adj deposition))) and (438/676.ccls. and (ald or (atomic adj layer adj deposition))) not (438/656.ccls. and (ald or (atomic adj layer adj deposition))) not (438/655.ccls. and (ald or (atomic adj layer adj deposition))) not (438/651.ccls. and (ald or (atomic adj layer adj deposition))) not (438/650.ccls. and (ald or (atomic adj layer adj deposition))) not (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))	USPAT; US-PGPUB; EPO; DERWENT; IBM_TDB	2004/10/22 15:08
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